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10/821,879

PTO/SB/08A (08-00)

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Substitute for form 1449A/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)		Complete if Known			
		Application Number	Based on 09/149,289		
		Filing Date	September 9, 1998		
		First Named Inventor	Setsuo NAKAJIMA, et al.		
		Group Art Unit	2814		
Examiner Name	Douglas Wille				
Sheet	1	of	2	Attorney Docket Number	0756-7298

U.S. PATENT DOCUMENTS						
Examiner Initials ¹	Cite No. ¹	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code ² (if known)			
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Examiner Initials ¹	Cite No. ¹	Foreign Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Office ³	Number ³ Kind Code ² (if known)			
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		JP	43-006449		06/92	

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS			
Examiner Initials ¹	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ⁴
HP		Technical Digest of the International PVSEC-3, Tokyo, Japan 1987, "A Monolithic Series-Connected a Si-H Solar Cell on an Organic Polymer Film," pp. 391-394, K. Nakatani, K. Suzuki, H. Okaniwa.	
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		18 th IEEE PVSC (1985) pp. 1523-1528, "Mass Production Technology in a Roll-to-Roll Amorphous Silicon Solar Cell Process," H. Horimoto et al.	
HP		Technical Digest PVSEC-1 pp. 577-582, "Roll-to-Roll Mass Production Process for a Si- Solar Cell Fabrication," Stanford R. Ovshinsky.	

Examiner Signature		Date Considered	11/28/05
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